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(54) **LIQUID CRYSTAL DISPLAY DEVICE**

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USPC 349/106; 349/110

(58) **Field of Classification Search**
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See application file for complete search history.

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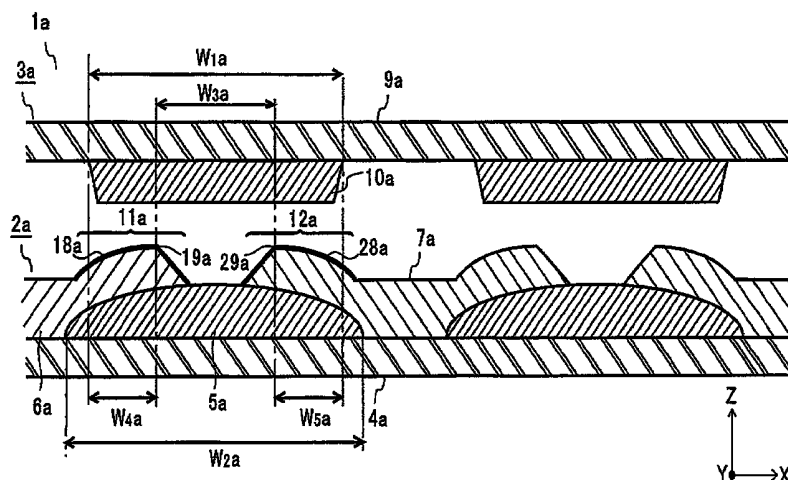
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Primary Examiner — Dung Nguyen

(57) **ABSTRACT**

A liquid crystal display device is provided which prevents variation in display from being caused due to misalignment of positions of exposure heads and/or error in assembly, and which is excellent in display quality. A liquid crystal display device 1 includes: a color filter 2 and a TFT substrate 3 which are bonded so as to oppose each other; and liquid crystal (not shown) sealed in a space formed therebetween. The color filter 2 includes: a substrate 4; black matrixes 5 provided on the substrate 4; and a plurality of colored layers 6 and 7 which partially overlap the black matrixes 5 at each pixel position. Vertices of ridges 18a and 28a formed by the colored layers 6 and 7 overlapping the black matrix 5 are positioned in an area where upper edges 19a and 29a, respectively, which continue in the Y-axis direction, are shielded from light by a light shielding section 10a of the TFT substrate 3.

6 Claims, 8 Drawing Sheets



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FIG. 1

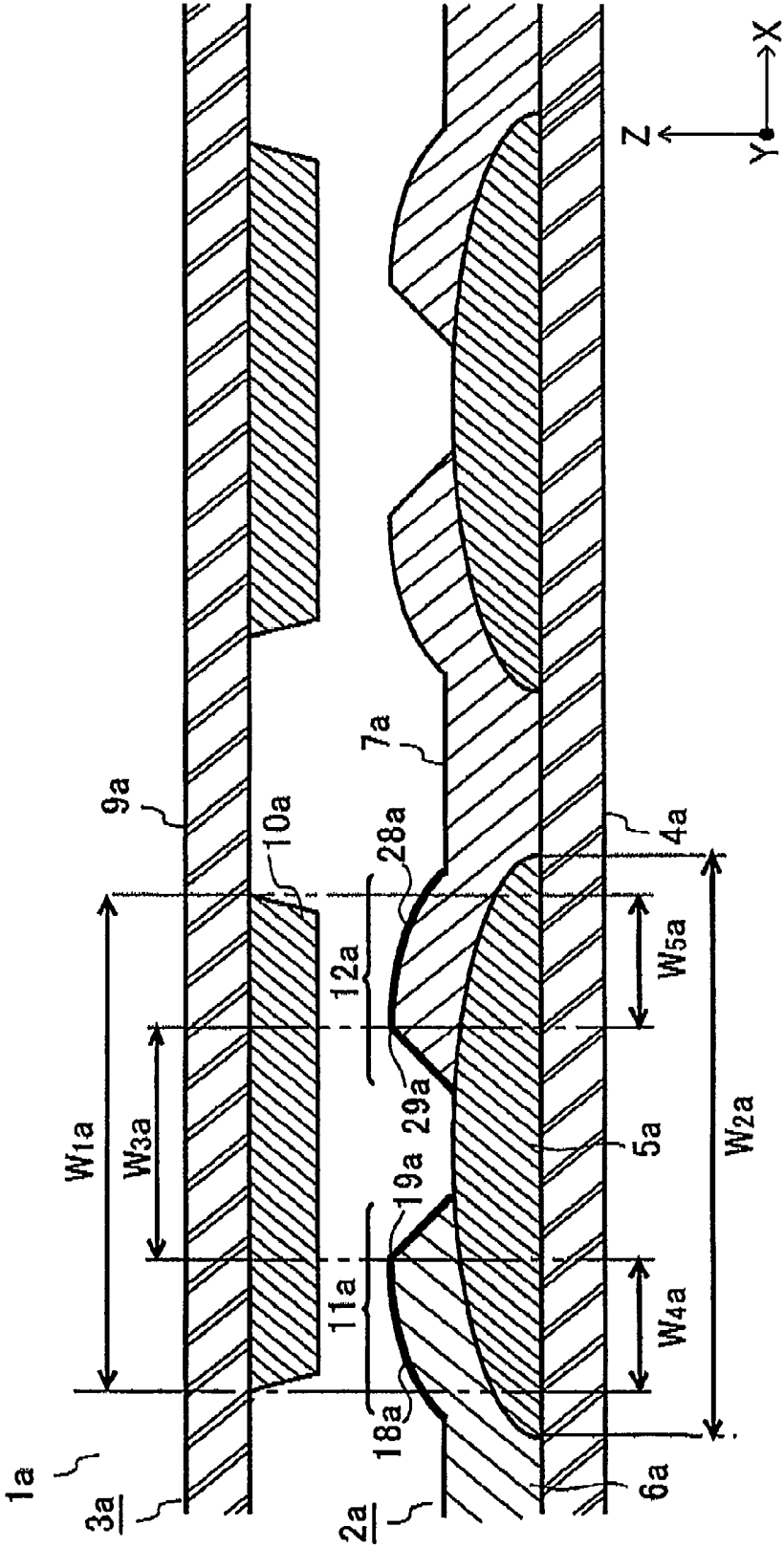
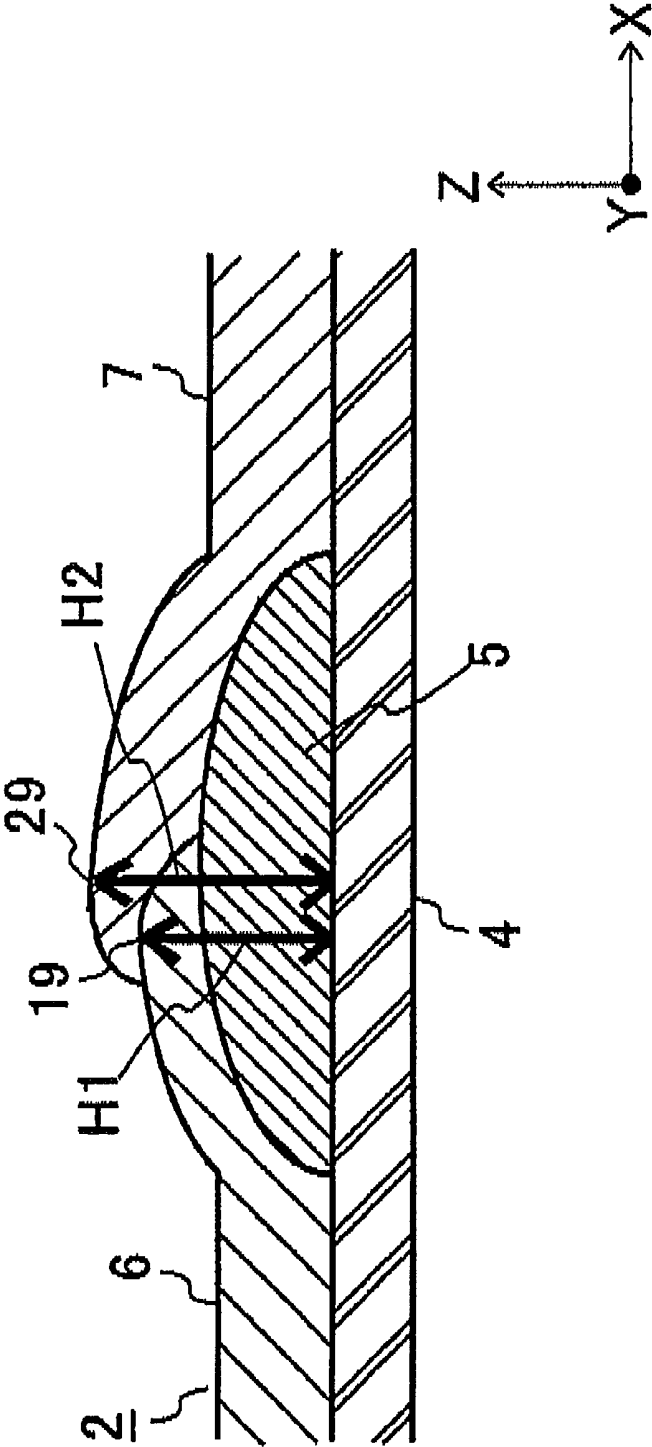


FIG.2



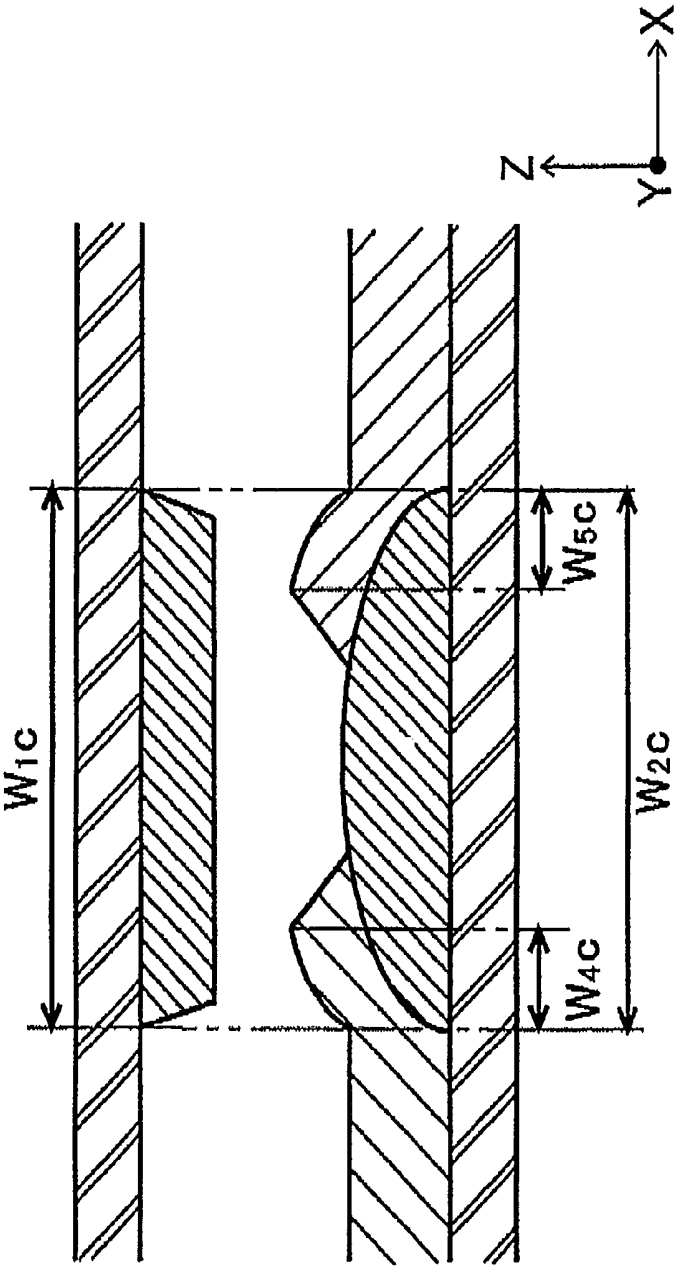


FIG.4

FIG. 5

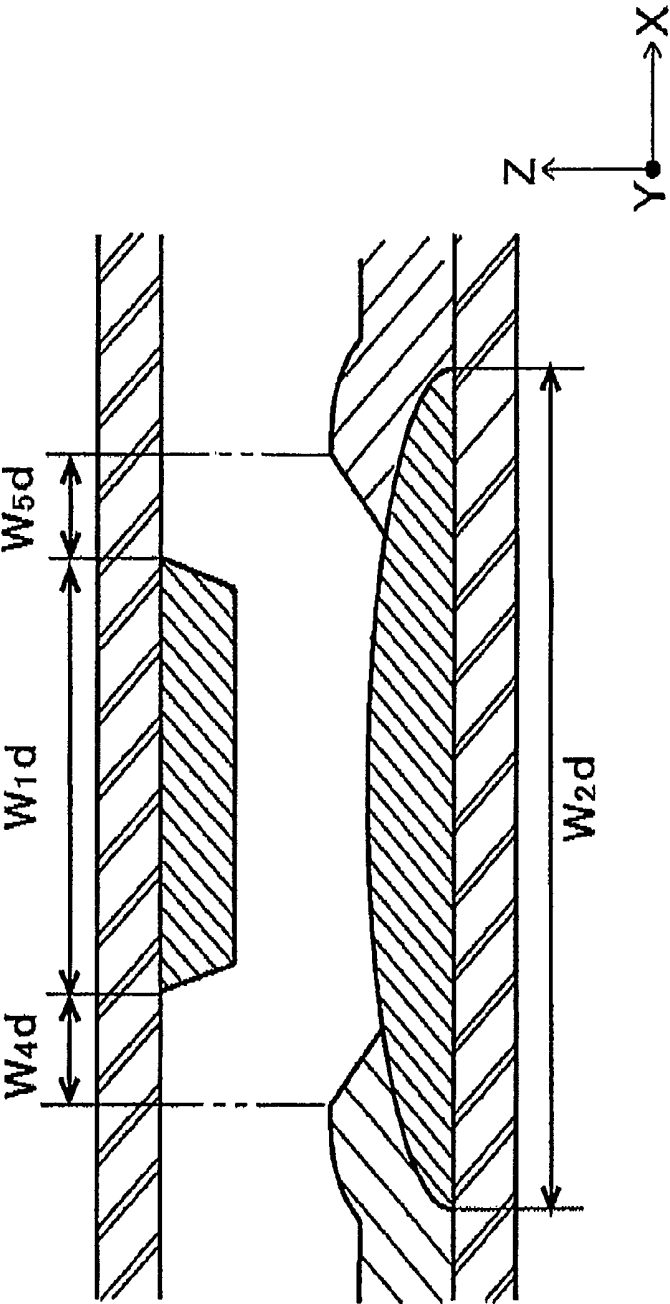


FIG. 6

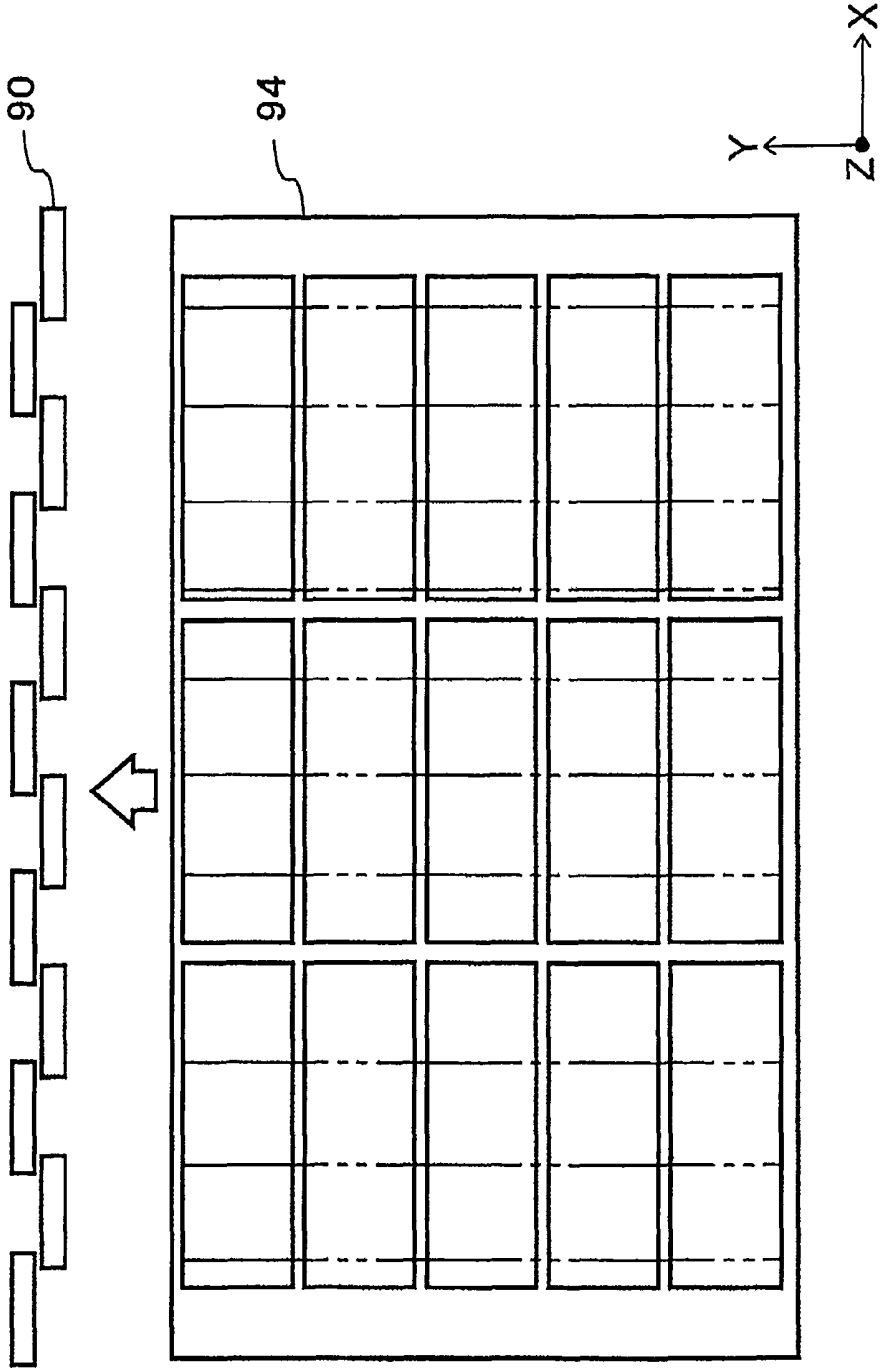


FIG. 7
RELATED ART

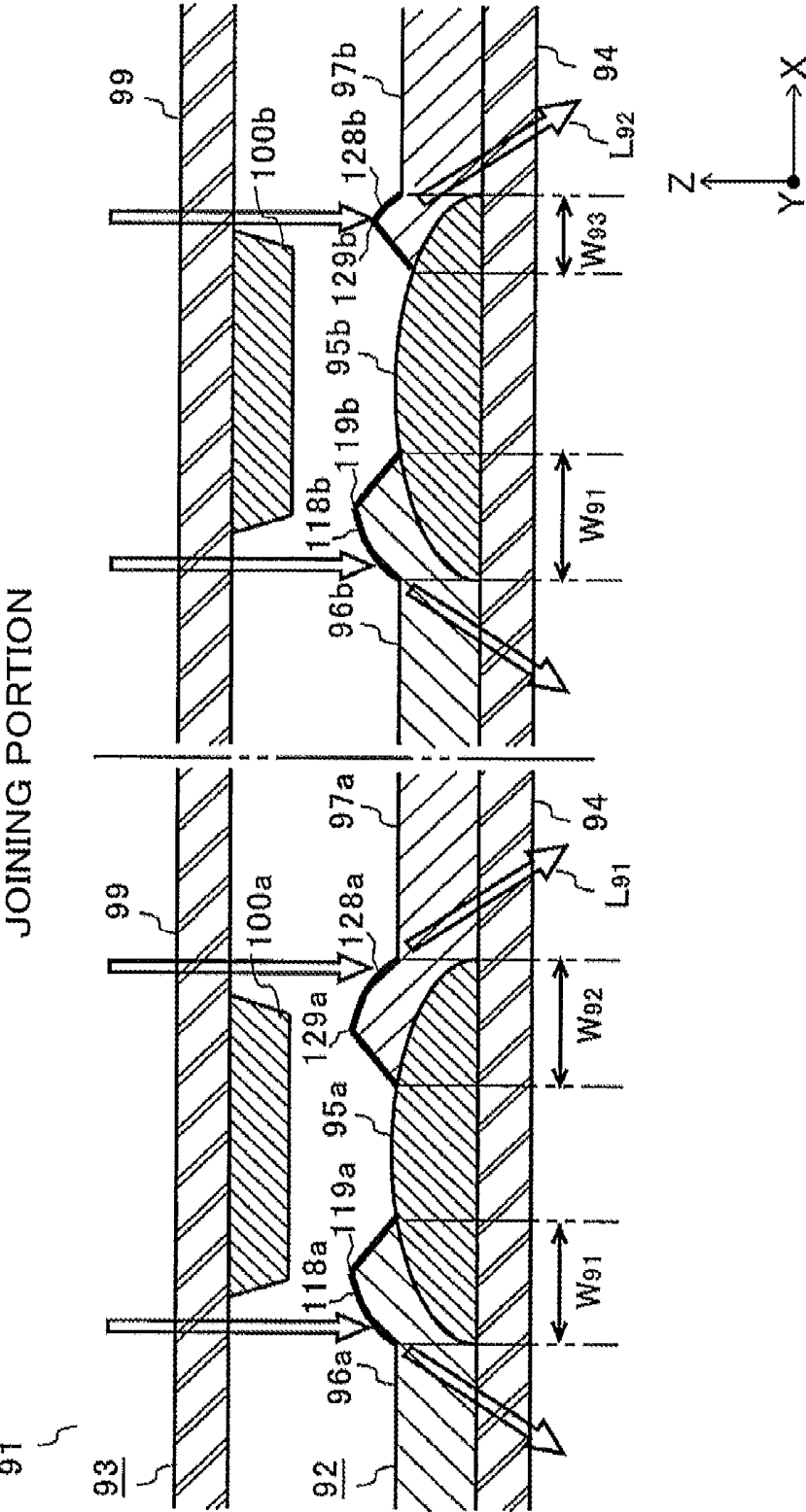
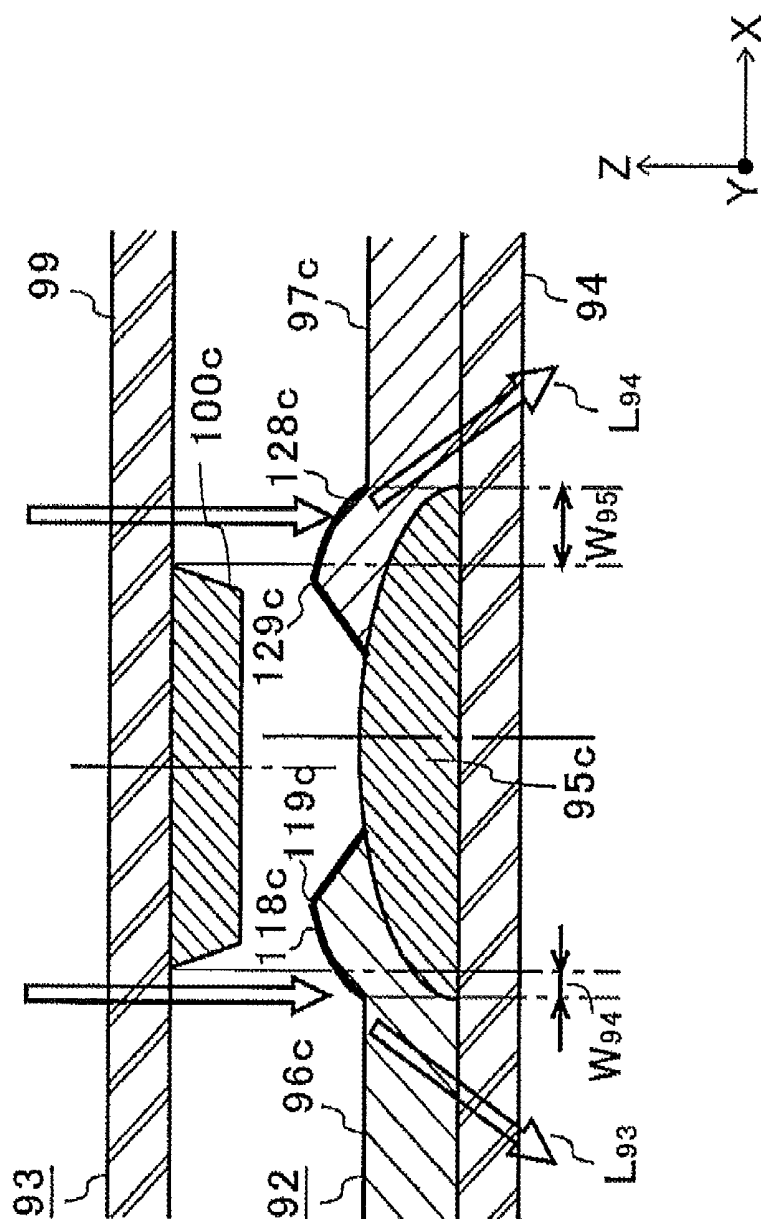


FIG. 8
RELATED ART



LIQUID CRYSTAL DISPLAY DEVICE

CROSS-REFERENCE TO RELATED APPLICATIONS

This application claims the benefit under 35 U.S.C. Section 371, of PCT International Application No. PCT/JP2010/003074, filed Apr. 28, 2010, which claimed priority to Japanese Application No. 2009-110488, filed Apr. 30, 2009 in the Japanese Patent Office, the disclosures of which are hereby incorporated by reference.

BACKGROUND

1. Field

The present invention relates to liquid crystal display devices each having liquid crystal sealed between a color filter and a thin film transistor (TFT) substrate.

2. Description of Related Art

A color filter for use in a liquid crystal display device includes, on a substrate, colored layers of three colors, that is, red, green, and blue, and black matrixes, and the colored layers form pixels, and the black matrixes are provided between each pixel for blocking light. A TFT substrate having a plurality of thin film transistors (including pixel electrodes, switching elements formed of a semiconductor, and insulating film layers), and a source wiring and a gate wiring, is provided so as to oppose the color filter. Liquid crystal is sealed between the color filter and the TFT substrate.

In a process of producing the color filter, patterning is performed in a photolithography method to form the colored layers and the black matrixes. At this time, an exposure method (hereinafter, referred to as a "small mask continuous exposure method") using a plurality of small photomasks may be used.

FIG. 6 is a schematic diagram illustrating an exposure method used in the process of producing a color filter, and illustrating the small mask continuous exposure method.

In an exposure device for use in the small mask exposure method, a plurality of exposure heads 90 each having a mask smaller than a substrate 94 are positioned so as to be aligned in a plurality of rows. The exposure heads 90 in a row are positioned between adjacent exposure heads 90 in another row without space such that pitches between the mask patterns formed on each photomask become uniform.

An exposure process is repeated multiple times, while the substrate 94 having the photoresist applied thereto is being conveyed in the Y-axis positive direction (the direction indicated by an arrow in the drawings) relative to the plurality of exposure heads 90 aligned as described above, so that pattern can be formed over the entire surface of the substrate 94 through baking

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SUMMARY

Problems Addressed by Embodiments of the Invention

In a case where colored patterns are formed on the color filter by using the small mask continuous exposure method as described above, a problem arises that variations of the formed colored patterns occur, due to misalignment of the

exposure heads 90 including joining portions thereamong, in portions (near portions indicated by the alternate long and two short dashes lines in FIG. 6. Hereinafter, these portions may be also referred to as "joining portions") which are exposed to light in the joining portions of the exposure heads 90

FIG. 7 is a cross-sectional view of an exemplary schematic structure of a conventional liquid crystal display device. The alternate long and two short dashes line in FIG. 7 corresponds to any one of the alternate long and two short dashes lines indicated in FIG. 6, and represents a position of the joining portion on the substrate. A portion of the color filter indicated to the left of the alternate long and two short dashes line, and a portion of the color filter indicated to the right of the alternate long and two short dashes line are exposed to light by different exposure heads, respectively.

A conventional liquid crystal display device 91 includes a color filter 92 and a TFT substrate 93 which are positioned so as to oppose each other. On a substrate 94 of the color filter 92, black matrixes 95a and 95b, and colored layers 96a, 96b, 97a, and 97b are formed. On a substrate 99 forming the TFT substrate 93, light shielding sections 100a and 100b are formed so as to oppose the black matrixes 95a and 95b, respectively. The light shielding sections 100a and 100b are each a region in which metal wiring connected to the thin film transistor provided on the TFT substrate 93 is formed.

In pixel areas to the left of the joining portion (the alternate long and two short dashes line), the colored layers 96a and 97a formed on pixel positions, respectively, on the substrate 94 partially overlap the black matrix 95a. Since the colored layer 96a overlaps the black matrix 95a, a ridge 118a (the thick line portion in the drawings) having an upper edge 119a as a vertex is formed, and since the colored layer 97a overlaps the black matrix 95a, a ridge 128a having an upper edge 129a as a vertex is formed. It is to be noted that each of the upper edges 119a and 129a continues linearly in the Y-axis direction. Further, an overlap width of an overlap portion in which the colored layer 96a overlaps the black matrix 95a is represented as W_{91} , and an overlap width of an overlap portion in which the colored layer 97a overlaps the black matrix 95a is represented as W_{92} .

Next, also in pixel areas to the right of the joining portion (the alternate long and two short dashes line), the colored layers 96b and 97b formed on pixel positions, respectively, on the substrate 94 partially overlap the black matrix 95b. Similarly, since the colored layer 96b overlaps the black matrix 95b, a ridge 118b having an upper edge 119b as a vertex is formed, and since the colored layer 97b overlaps the black matrix 95b, a ridge 128b having an upper edge 129b as a vertex is formed. An overlap width of an overlap portion in which the colored layer 96b overlaps the black matrix 95b is represented as W_{91} , which is the same as the overlap width in the pixel areas to the left of the joining portion. However, in a case where misalignment of positions of the exposure heads occurs when the colored layer 97b is exposed to light, an overlap width of an overlap portion in which the colored layer 97b overlaps the black matrix 95b is represented as W_{93} ($< W_{92}$). Further, the upper edge 129b is located outside an area which is shielded from light by the light shielding section 100b.

In a case where the overlap width of the overlap portion in which the colored layer overlaps the black matrix is different between in the area to the left of the joining portion and in the area to the right of the joining portion, light L_{91} transmitted through the area to the left of the joining portion and light L_{92} transmitted through the area to the right of the joining portion are outputted in different manners. Further, in a case where the upper edge 129b is located outside an area which is

shielded from light by the light shielding section, the light L_{92} is transmitted through the upper edge **129b**. As a result, a difference in output manner between the light L_{91} transmitted through the area to the left of the joining portion and the light L_{92} transmitted through the area to the right of the joining portion is increased. The difference in output of the light between in the area to the left of the joining portion and in the area to the right of the joining portion causes variations in image display in the liquid crystal display device.

Further, the liquid crystal display device using the color filter having the structure shown in FIG. 7 has the following problems.

FIG. 8 is a cross-sectional view of another exemplary schematic structure of a conventional liquid crystal display device.

When the liquid crystal display device is assembled, the substrates are bonded to each other such that the center line of a light shielding section **100c** on the TFT substrate **93** are aligned with the center line of a black matrix **95c**. However, as shown in FIG. 8, error in assembly may cause misalignment of the central lines of both of them. In this case, even if an overlap width of an overlap portion in which a colored layer **96c** overlaps the black matrix **95c**, and an overlap width of an overlap portion in which a colored layer **97c** overlaps the black matrix **95c**, are almost the same, a protrusion width W_{94} and a protrusion width W_{95} by which protrusions from the light shielding section **100c** occur are different from each other. In this case, an output manner of light L_{93} and an output manner of light L_{94} on both sides, respectively, of the black matrix are significantly different from each other, resulting in variation in image display. Further, in a case where error in assembly is further increased, it is assumed that an upper edge **119c** or **129c** may protrude so as to be outside an area which is shielded from light by the light shielding section. In an upper edge portion which protrudes so as to be outside the light-shielded area, variation of light transmission characteristic is significantly increased as compared to in the other portions, thereby leading to increase of variation in display.

Therefore, an object of the present invention is to make available a liquid crystal display device which can prevent variation in display from being caused due to misalignment of positions of exposure heads and/or error in assembly, and which is excellent in display quality.

Solutions to the Problems

The present invention is directed to a liquid crystal display device having a plurality of pixels aligned in a first direction and a second direction orthogonal to the first direction. The liquid crystal display device includes: a color filter having formed on a substrate light shielding layers, and a plurality of colored layers which partially overlap the light shielding layers in at least the first direction; a TFT substrate having a plurality of light shielding sections which extend in the second direction at such positions as to oppose the light shielding layers; and liquid crystal sealed between the color filter and the TFT substrate. Ridges extending in the second direction are formed by the plurality of colored layers overlapping the light shielding layers in the first direction. At least upper edges of the ridges are shielded from light by the plurality of light shielding sections.

Advantageous Effects of Embodiments

According to the present invention, a liquid crystal display device can be realized in which the upper edges of the ridges formed by the colored layers overlapping the black matrixes

are positioned behind wiring and are shielded from light, and thus no variation in light emission is caused due to the upper edges of the ridges even when misalignment of positions of the overlap portions is caused due to photomasks being misaligned in position during exposure, and/or due to error in assembly, and in which display quality is excellent.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a cross-sectional view of a schematic structure of a liquid crystal display device according to a first embodiment.

FIG. 2 is a cross-sectional view illustrating positions of upper edges of ridges in another exemplary case.

FIG. 3 is a cross-sectional view of a schematic structure of a liquid crystal display device according to a second embodiment.

FIG. 4 is a cross-sectional view of a schematic structure of a liquid crystal display device according to example 3.

FIG. 5 is a cross-sectional view of a schematic structure of a liquid crystal display device according to comparative example.

FIG. 6 is a schematic diagram illustrating an exposure method used in a process for producing a color filter.

FIG. 7 is a cross-sectional view of an exemplary schematic structure of a conventional liquid crystal display device.

FIG. 8 is a cross-sectional view of another exemplary schematic structure of a conventional liquid crystal display device.

DESCRIPTION OF EMBODIMENTS

First Embodiment

FIG. 1 is a cross-sectional view of a schematic structure of a liquid crystal display device according to a first embodiment of the present invention. FIG. 2 is a cross-sectional view illustrating positions of upper edges of ridges in another exemplary case.

A liquid crystal display device **1a** according to the first embodiment has a plurality of pixels aligned in the X-axis direction and the Y-axis direction, and includes: a color filter **2a** and a TFT substrate **3a** which are bonded so as to oppose each other; and liquid crystal (not shown) sealed in a space formed between the color filter **2a** and the TFT substrate **3a**. A not-illustrated light source is positioned above the outer surface (the upper portion in FIG. 1) of the TFT substrate **3a**.

The color filter **2a** includes: a substrate **4a**; black matrixes **5a** provided on the substrate **4a**; and a plurality of colored layers **6a** and **7a** formed on pixel positions, respectively. The colored layers **6a** and **7a** form overlap portions **11a** and **12a**, respectively, in which the respective colored layers partially overlap the black matrix **5a** in the X-axis direction. Further, since the colored layers **6a** and **7a** overlap the black matrix **5a**, the colored layers are raised to form ridges **18a** and **28a**, respectively (thick line portions in the drawings). The vertices of the ridges **18a** and **28a** each continue in the Y-axis direction, to form linear upper edges **19a** and **29a**, respectively.

Photoresist coated on the substrate **4a** is patterned by using the photolithography method, thereby forming the colored layers **6a** and **7a**. Pixels of a first color (for example, red) and pixels of a second color (for example, green) can be formed by the small mask continuous exposure method (FIG. 6) using a plurality of small photomasks, and pixels of a third color (for example, blue) can be formed by using a proximity exposure method. Specifically, as described with reference to FIG. 6, by using the small mask exposure method, while the

substrate 4a is being conveyed in the Y-axis direction, the opening pattern of the photomask provided in each exposure head is sequentially transferred by using a light source which is constantly lit up. As a result, the colored layers of the first color and the second color are formed into stripes extending in the Y-axis direction. It is to be noted that the opening pattern of the photomask may be intermittently transferred by using a blinking light source, to form dotted colored layers. Thereafter, for example, the entirety of the colored layers of the third color is formed at one time by using the proximity exposure method in which a single photomask is used. It is to be noted that colored layers of a fourth color (for example, yellow), in addition to red, blue, and green as described above, may be formed.

As shown in FIG. 2, the colored layer 6 and the colored layer 7 are likely to partially overlap each other on the black matrix 5 in the X-axis direction. Also in this case, the upper edge of each colored layer needs to be shielded from light by a light shielding section. Thus, also when the colored layer 6 and the colored layer 7 partially overlap each other, a position at which the distance from the substrate 4 to the surface of the colored layer 6 is maximum (H1) is defined as the upper edge 19, and a position at which the distance from the substrate 4 to the surface of the colored layer 7 is maximum (H2) is defined as the upper edge 29, as in a case shown in FIG. 1.

The TFT substrate 3a includes a plurality of thin film transistors (not shown), and a plurality of light shielding sections 10a extending in the Y-axis direction. The light shielding sections 10a are each a region in which metal wiring (source wiring, gate wiring, or both of them) connected to the thin film transistors is formed.

In the first embodiment, since a width W_1a of the light shielding section 10a on the TFT substrate 3a is narrower than a width W_2a of each black matrix, the overlap portions 11a and 12a on the color filter 2a each include a portion which is not shielded from light by the light shielding section 10a. However, the upper edges 19a and 29a are shielded from light by the light shielding section 10a. More specifically, the upper edges 19a and 29a are positioned between lines obtained by projecting, on the substrate 4a, the edges of the light shielding section 10a in the X-axis direction. A difference ($W_1a - W_3a$) occurs between the width W_1a of the light shielding section 10a, and a distance W_3a between the upper edges 19a and 29a. Therefore, a distance W_4a is formed between the upper edge 19a and the line obtained by projecting, on the substrate 4a, a corresponding one of the edges of the light shielding section 10a in the X-axis direction, and a distance W_5a is formed between the upper edge 29a and the line obtained by projecting, on the substrate 4a, the other of the edges of the light shielding section 10a in the X-axis direction.

Also in the liquid crystal display device 1a having the structure described above, misalignment of positions in the colored layers may occur due to, for example, low accuracy for aligning each exposure head with the substrate. Specifically, a position at which the colored layer in a first area which is exposed to light by using a certain exposure head is formed, and a position at which the colored layer in a second area (area which is exposed to light by using another exposure head) adjacent to the first area is formed may be misaligned. As a result, the position of the upper edge in the first area and the position of the upper edge in the second area are misaligned. In addition, the light shielding section and the upper edge may be misaligned, in some cases, due to error in bonding the color filter 2a and the TFT substrate 3a to each other.

However, in the liquid crystal display device 1a according to the present embodiment, the difference ($W_1a - W_3a$) occurs

between the width W_1a of the light shielding section 10a, and the distance W_3a between the upper edges 19a and 29a. Therefore, the misalignment in position as described above can be absorbed to some degree, and the upper edges 19a and 29a can be kept inside the light shielding area of the light shielding section 10a. Thus, unlike in the conventional arts, it is possible to effectively reduce variation in image display which occurs due to light transmitted through the upper edge being outputted to display pixels.

It is to be noted that a value of the difference ($W_1a - W_3a$) is preferably greater than or equal to 8 μm . This is because the difference ($W_1a - W_3a$) needs to be greater than or equal to 4 μm in order to absorb misalignment in position which may be caused due to, for example, low accuracy for aligning each exposure head with the substrate, and the difference ($W_1a - W_3a$) needs to be greater than or equal to 4 μm in order to absorb misalignment in position caused when the color filter 2a and the TFT substrate 3a are bonded to each other.

As described above, according to the first embodiment, the liquid crystal display device 1a can be realized which does not cause, even in a case where misalignment in position occurs in the joining portions of the exposure heads when the exposure process is performed by using the small mask continuous exposure method in order to produce the color filter 2a, variation in quality of display image due to the misalignment, and which is excellent in display quality.

Second Embodiment

FIG. 3 is a cross-sectional view of a schematic structure of a liquid crystal display device according to a second embodiment of the present invention.

A liquid crystal display device 1b according to the second embodiment is different from the liquid crystal display device according to the first embodiment in that, in the overlap portion in which the colored layer and the black matrix overlap each other, ranges shielded from light are different. Specifically, the entirety of the overlap portion is shielded from light by the light shielding section.

According to the second embodiment, a width W_1b of a light shielding section 10b is determined so as to be greater than a width W_2b of the black matrix 5, and overlap portions 11b and 12b are shielded from light by the light shielding section 10b. More specifically, the overlap portions 11b and 12b are positioned between lines obtained by projecting, on the substrate 4b, the edges of the light shielding section 10b in the X-axis direction. Further, a difference ($W_1b - W_2b$) occurs between the width W_1b of the light shielding section 10b and the width W_2b of the black matrix 5b. Therefore, a distance W_8 is formed between the overlap portion 11b and the line obtained by projecting, on the substrate 4b, a corresponding one of the edges of the light shielding section 10b in the X-axis direction, and a distance W_9 is formed between the overlap portion 12b and the line obtained by projecting, on the substrate 4b, the other of the edges of the light shielding section 10b in the X-axis direction.

Also in the liquid crystal display device 1b having the structure as described above, overlap widths W_6b and W_7b of the overlap portions 11b and 12b, respectively, may deviate from predefined values due to the exposure heads being misaligned in position when the colored layers 6b and 7b are exposed to light. However, in the liquid crystal display device 1b according to the present embodiment, the entirety of each of the overlap portions 11b and 12b is positioned within a range obtained by the light shielding section 10b being projected, and the entirety thereof is shielded from light. Therefore, it is possible to avoid variation in image display caused

due to light transmitted through the overlap portion **11b** and light transmitted through the overlap portion **12b** being outputted in different manners.

Further, the difference ($W_1b - W_2b$) occurs between the width W_1b of the light shielding section **10b** and the width W_2b of the black matrix **5b**. As a result, misalignment in position caused when the color filter **2b** and the TFT substrate **3b** are bonded to each other is absorbed to some degree, and the entirety of each of the overlap portions **11b** and **12b** can be kept inside the light shielding area of the light shielding section **10b**. A value of the difference ($W_1b - W_2b$) is preferably greater than or equal to $4\text{ }\mu\text{m}$ in view of error in assembly, and is preferably not greater than $8\text{ }\mu\text{m}$ in view of reduction in aperture ratio caused due to enlargement of the light shielding section.

In the liquid crystal display device **1b** according to the second embodiment, the entirety of each of the overlap portions **11b** and **12b** is shielded from light by the light shielding section **10b**. Therefore, it is possible to not only avoid variation in image display caused due to output of light transmitted through the upper edge of a ridge, but also avoid variation in image display caused due to the widths of the overlap portions being different. As a result, it is possible to provide a liquid crystal display device which enables display quality to be improved as compared to the liquid crystal display device according to the first embodiment.

It is to be noted that, although a black matrix is used as a light shielding layer in each of the first and the second embodiments, the present invention is not limited thereto, and, for example, an electrode layer that is formed of thin metal film and formed on the substrate may be used.

EXAMPLES

Hereinafter, examples where the present invention was implemented in practice will be described.

A color filter having red, blue, and green colored layers formed on its substrate was produced by using the small mask continuous exposure method and the proximity exposure method as described above. Further, a TFT substrate was produced by light shielding sections each formed of source or gate wiring being formed on a substrate. At this time, the liquid crystal display devices were produced such that the width of the light shielding section, the width of the black matrix, and a distance between the upper edge of each ridge, and a line obtained by projecting, on the substrate, a corresponding one of the edges of the light shielding section, have values indicated in examples 1 to 3 and a comparative example described below. Variation in image display on each of the liquid crystal display devices was visually observed, and evaluation was represented as "A: no variation in display occurred, B: few variation in display occurred, or C: variation in display occurred". The result of the evaluation is indicated in table 1. It is to be noted that the width of the light shielding section, the width of the black matrix, and the distance between the upper edge of each ridge, and the corresponding one of the projected edges of the light shielding section each represents a value in the X-axis direction. In examples 1 to 3, the upper edges of the ridges were positioned in areas which were shielded from light by the light shielding section. In comparative example 1, the upper edges of the ridges were positioned in areas which were not shielded from light by the light shielding section.

Example 1

A liquid crystal display device according to example 1 had the structure shown in FIG. 3. The width (W_1a) of the light

shielding section was $22\text{ }\mu\text{m}$, the width (W_2a) of the black matrix was $16\text{ }\mu\text{m}$, and the distances (W_4a and W_5a) between the upper edges of the ridges, and the lines obtained by projecting, on the substrate, the edges of the light shielding section **10**, respectively, were each $4\text{ }\mu\text{m}$ (the upper edges were positioned between the projected lines of the light shielding section).

Example 2

A liquid crystal display device according to example 2 had the structure shown in FIG. 1. The width (W_1b) of the light shielding section was $18\text{ }\mu\text{m}$, the width (W_2b) of the black matrix was $28\text{ }\mu\text{m}$, and the distances (W_4b and W_5b) between the upper edges of the ridges, and the lines obtained by projecting, on the substrate, the edges of the light shielding section **10**, respectively, were each $4\text{ }\mu\text{m}$.

Example 3

A liquid crystal display device according to example 3 had a structure shown in FIG. 4. The width (W_1c) of the light shielding section was $22\text{ }\mu\text{m}$, the width (W_2c) of the black matrix was $22\text{ }\mu\text{m}$, and the distances (W_4c and W_5c) between the upper edges of the ridges, and the lines obtained by projecting, on the substrate, the edges of the light shielding section **10**, respectively, were each $4\text{ }\mu\text{m}$.

Comparative Example

A liquid crystal display device according to a comparative example had a structure shown in FIG. 5. The width (W_1d) of the light shielding section was $18\text{ }\mu\text{m}$, the width (W_2d) of the black matrix was $28\text{ }\mu\text{m}$, and the distances (W_4d and W_5d) between the upper edges of the ridges, and the lines obtained by projecting, on the substrate, the edges of the light shielding section **10**, respectively, were each $-4\text{ }\mu\text{m}$ (the upper edges were not positioned between the projected lines of the light shielding section).

TABLE 1

	Present Invention			Comparative sample
	Example 1	Example 2	Example 3	Comparative example
Width W_{1x} (μm) of light shielding section	22	18	22	18
Width W_{2x} (μm) of black matrix	16	28	22	28
Distances W_{4x} and W_{5x} (μm) between upper edges and projected edges of light shielding section, respectively	4	4	4	-4
Display quality	A	B	B	C

x: 1 to 4 (examples 1 to 4)

According to the results indicated in Table 1, in examples 1 to 3 in which at least the upper edges of the ridges were shielded from light by the light shielding section, few variation in image display occurred in the liquid crystal display devices, so that display quality of each of the liquid crystal display devices was improved. Further, in example 1 in which the entirety of the overlap portions were shielded from light, the display quality was greatly improved.

Industrial Applicability

The present invention is applicable to, for example, a liquid crystal display device including a color filter.

Reference Signs	
1a, 1b	liquid crystal display device
2a, 2b	color filter
3a, 3b	TFT substrate
4a, 4b	substrate
5a, 5b	black matrix
6a, 6b, 7a, 7b	colored layer
9a, 9b	substrate
10a, 10b	light shielding section
11a, 11b, 12a, 12b	overlap portion
18a, 18b, 28a, 28b	ridge
19a, 19b, 29a, 29b	upper edge

The invention claimed is:

1. A liquid crystal display device having a plurality of pixels aligned in a first direction and a second direction orthogonal to the first direction, the liquid crystal display device comprising:

a color filter having formed on a substrate light shielding layers, and a plurality of colored layers which partially overlap the light shielding layers in at least the first direction;

a TFT substrate having a plurality of light shielding sections which are positioned so as to oppose the light shielding layers, and extend in the second direction; and liquid crystal sealed between the color filter and the TFT substrate, wherein

ridges extending in the second direction are formed by the plurality of colored layers overlapping the light shielding layers in the first direction, at least upper edges of the ridges are shielded from light by the plurality of light shielding sections, and

a difference between a distance between the upper edges of a pair of the ridges which are shielded from light by a corresponding one of the plurality of light shielding sections, and a width of the corresponding one of the plurality of light shielding sections in the first direction, is greater than or equal to 8 μm .

2. The liquid crystal display device according to claim 1, wherein the entirety of portions in which the plurality of colored layers overlap the light shielding layers in the first direction is included in areas shielded from light by the plurality of light shielding sections.

3. The liquid crystal display device according to claim 1, wherein a width of each of the plurality of light shielding sections in the first direction is greater than a width of a corresponding one of the light shielding layers in the first direction.

4. The liquid crystal display device according to claim 3, wherein a difference between the width of each of the plurality of light shielding sections in the first direction and the width of the corresponding one of the light shielding layers in the first direction is greater than or equal to 4 μm , and is not greater than 8 μm .

5. The liquid crystal display device according to claim 1, wherein

the plurality of colored layers overlap the light shielding layers in the first direction by a first overlap width in a first area including a predetermined number of pixel lines, and

the plurality of colored layers overlap the light shielding layers in the first direction by a second overlap width different from the first overlap width, in a second area which is adjacent, in the first direction, to the first area, and which includes a predetermined number of pixel lines.

6. The liquid crystal display device according to claim 1, wherein the thickness of each of the light shielding layers is reduced outward in the first direction.

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专利名称(译)	液晶显示装置		
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摘要(译)

提供一种液晶显示装置，其防止由于曝光头的位置未对准和/或组装错误引起的显示变化，并且显示质量优异。液晶显示装置1包括：滤色器2和TFT基板3，它们彼此相对地粘合；液晶（未示出）密封在它们之间形成的空间中。滤色器2包括：基板4；黑矩阵5设置在基板4上；多个着色层6和7在每个像素位置处与黑色矩阵5部分重叠。由与黑色矩阵5重叠的着色层6和7形成的脊18a和28a的顶点位于通过光屏蔽分别在Y轴方向上连续的上边缘19a和29a被遮挡的区域中。TFT基板3的截面10a。

